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Two-dimensional metal-dielectric hybrid-structured film with titanium oxide for enhanced visible light absorption and photo-catalytic application



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Abstract

Two-dimensional design based on ultrathin TiO_2 film for enhanced visible light absorption and photo-catalytic applications is reported, which mainly consists of three layers of gold film, TiO_2 film, and gold nanoparticles (Au NPs). The Au and TiO_2 films are produced by e-beam evaporation and atomic layer deposition, respectively, in a carefully controlled way to minimize surface roughness. As compared with bare TiO_2 film, the Au NPs/ TiO_2 /Au film significantly increased the photoactivity over the entire UV and visible wavelength range. The Au film increases the light absorption in the UV region with TiO_2 acting as an impedance-matching layer, while the Au NPs increase the light absorption in the visible region due to the plasmonic resonance effects, increasing the photocurrent under visible light. 3D numerical simulation results suggest that the Au film also plays an important role in enhancing the electrical field

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intensity at the TiO_2 film in contact with Au NPs, by efficient excitation of localized surface plasmon resonances, thereby, contributing to the enhanced photoactivity of the film in the visible range. This simple system may serve as an efficient platform for solar energy conversion utilizing the whole UV-visible range of solar spectrum based on two-dimensional plasmonic photoelectrodes.

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Introduction

Photocatalytic water splitting to produce molecular hydrogens and oxygen in artificial photosynthetic system has been practiced in laboratories for decades. So far, many materials have been suggested until now, however, titanium dioxide (TiO_2) is still one of attractive photoelectrodes due to its strong optical absorption, high chemical stability, environmental benignity, and low cost [1]. There have been many reports which show the photoconversion efficiencies to enable the development and commercialization of TiO2related materials [2-4]. However, the TiO₂-based photoelectrodes still suffer from many drawbacks that limit the successful commercialization such as the predominant absorption in the UV region due to the wide bandgap $(\sim 3.4 \text{ eV})$ and the slow water oxidation kinetics due to the valence band far away ($\sim 1.17 \text{ eV}$) below the water oxidation level. These resulted in a dramatic decrease in the energy conversion efficiency.

Among the challenges of overcoming the issues is the development of photoelectrodes with various nanostructures such as 0-D nanodots, 1-D nanowires, 2-D ultrathin films and 3-D nanostructures [5-8]. Recently, several structural designs such as hierarchical [9], branched [10] assemblies of nanoscale materials are effective in increasing the UV-vis absorption, consequently, enhancing water-splitting efficiency. Several methods of dopant incorporation into TiO₂ such as metals [11,12] or non-metals [13-15] were highly spotlighted in a semiconductor viewpoint, which provides suitable energy levels for maximizing the light absorption, carrier lifetime (by decreasing the diffusion length), and water redox kinetics [16]. However with these doping strategies, it may occur undesired recombination of photo-generated carriers, which dramatically reduces the efficiency of photoelectrochemical (PEC) cells.

Not only this strategies, but the incorporations of plasmonic metal nanoparticles (i.e. Au) to TiO_2 structures have been shown to enhance the water-splitting efficiency especially in the visible region due to strong localized surface plasmon resonance (LSPR) excitation from collective oscillations of the surface electrons on metal nanoparticles [17-22]. The plasmonic metal nanoparticles sensitize TiO_2 to visible light and increase the light absorption, injecting additional hot electrons to TiO_2 and leaving behind holes for water oxidation. This approach was found to be much effective in semiconductor with very confined dimension than the doping sensitization. The LSPR can be intensified by the electromagnetic interaction between adjacent metal nanoparticles, in which the resonance excitation is tuned by changing the size and distance between each nanoparticles,

as well as the kinds of metal; as the distance decreases, the resonant peaks get bigger and in Au nanoparticles, the peaks are observed in the higher wavelength than Ag nanoparticles [23]. According to the theoretical calculation, the spectral modulation in the excitation and the light absorption amplification can enhance the injection of the hot carriers toward the conduction band of the semiconductor [24]. However, in this approach, it is still unsatisfactory as only a few hot-carriers are transferred to surface via this localized SPR property, resulting in a low plasmonic conversion efficiency (\sim 1%) to water splitting [25].

Here, we demonstrate a simple approach for maximizing the light absorption in the entire UV-visible region, in which the photoelectrode consists of three layers of Au film, TiO_2 film, and Au nanoparticles (NPs). The layers are carefully produced using thin-film deposition technique, followed by the post annealing process. Although the electrode does not have a large surface-area-to-volume ratio, compared with previous nanostructures, we will show that a significant increase of the photoelectrochemical water oxidation rate can be achieved by optimal design of the three-layered photoelectrodes for broadband enhancement over the UV and visible part of solar spectrum. This ascribes to the increase of the light absorption in UV region due to the light reflected at TiO₂/Au thin film and in visible region due to the electric field enhancement at the TiO₂ film resulting from LSPR of Au NPs.

Experimental

Fabrication of 2-dimensional metastructured films

A glass substrate was used as the starting substrate. Before the fabrication of the photoelectrode, the substrate was cleaned with acetone, isopropanol, and de-ionized water. A thin layer of 100-nm-thick Au was deposited on the glass substrate using e-beam evaporation at a very slow deposition rate of less than 0.2 A/s. A 20 nm TiO_2 thin film was then coated onto the Au layer by using an atomic layer deposition (ALD) system (LUCIDA D100, NCD Technology, Korea). It was conducted with alternating exposure of titanium tetraisopropoxide (TTIP) and de-ionized water vapor at temperature of 200 °C with nitrogen as the carrier gas and purge gas at a pressure of 6.5 Pa. The pulse/purge times are 0.1 s/20 s for the precursors. The deposition rate of the TiO₂ layer is approximately 0.23 Å per cycle. The thickness of the TiO₂ film was measured from ellipsometer (M2000V, J. A. Woolam Co.). Finally, an Au film with the thickness ranging 3 to 7 nm was deposited over the film at a Download English Version:

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